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The variation of the pressure coefficient of resistivity in gallium arsenide with carrier concentration

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Abstract. The dependence of the resistivity of GaAs on pressure was investigated over a range of carrier concentrations. The change in effective mass of the electrons in the Γ_{1e} conduction band was found from measurements on samples with 10^{13} carriers cm⁻³. In heavily doped material, where impurity scattering determines the electron mobility, the pressure coefficient of resistivity dominated scattering occurs at about 10^{17} cm⁻³.

Introduction

The variation in resistivity of GaAs single crystals with pressures of up to 10 kbar is examined as a function of carrier concentration. The results are presented in two parts. At low carrier concentrations, the pressure coefficient of resistivity is caused by the change in effective mass of the electrons in the Γ_{tc} conduction band, and this is related to the pressure coefficient of the direct gap through $k\cdot p$ perturbation theory. In heavily doped material, however, where the Fermi level has risen above the bottom of the conduction band, the pressure coefficient of resistivity becomes strongly dependent on the carrier concentration.

Experimental techniques

Experimental techniques Full details of the preparation and characteristics of the n-type GaAs are shown in Table 1. The carrier concentrations range from 10^{13} cm⁻³ in undoped material to 10^{19} cm⁻³ in Se-doped material, while the Hall mobilities decrease from 8500 to 2000 cm² V⁻¹ s⁻¹ over the same region.

Four-probe resistivity measurements were made on a van der Pauw clover leaf at pressures of up to 10 kbar. A piston and cylinder device which contained a 1:1 mixture of paraffin and diala-C oil was used. Contacts to the crystal were passed through one piston using sheathed Chromel-Alumel thermocouples, brazed to the piston and sealed with epoxy resin. The pressures were recorded directly with a manganin gauge. A considerable increment in temperature accompanied each increase in pressure, but an equilibrium at 296°K was regained within a few minutes.

Table 1. The carrier concentrations and Hall mobilities at 300°K.

crystal	carrier concentration n (cm ⁻³)	Hall mobility (cm ² V ⁻¹ s ⁻¹)	dopant	of growth	
LE 39	3.9 x 1013	8300	none	liquid epitaxy	
A*	7.0×10^{14}	7700	unknown	unknown	
LE 19A	5.0 × 1015	6850	none	liquid epitaxy	
LE 43A	2.6 x 1016	5840	Se	liquid epitaxy	
D 303A	1.1 × 1017	4320	Se	vapour epitaxy	
LE 152	7.3 × 1017	3160	Se	liquid epitaxy	
LE 168	3.0 × 1018	2180	Se	liquid epitaxy	

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